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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/625,243	07/22/2003	Andrew Perry	LAM2P426	9295
25920	7590 04/05/2006		EXAMINER	
MARTINE PENILLA & GENCARELLA, LLP			KACKAR, RAM N	
710 LAKEW. SUITE 200	AY DRIVE		ART UNIT	PAPER NUMBER
	E, CA 94085	1763		
			DATE MAILED: 04/05/200	6

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)		
Office Action Summary		10/625,243	PERRY, ANDREW		
		Examiner	Art Unit		
		Ram N. Kackar	1763		
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
WHIC - Exter after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nety filed the mailing date of this communication. D (35 U.S.C. § 133).		
Status					
2a)⊠	Responsive to communication(s) filed on <u>17 Ja</u> This action is FINAL . 2b) This Since this application is in condition for allowar closed in accordance with the practice under <i>E</i>	action is non-final. nce except for formal matters, pro			
Dispositi	on of Claims				
5)□ 6)⊠ 7)□ 8)□	Claim(s) <u>8,9,19 and 21-23</u> is/are pending in the 4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed. Claim(s) <u>8-9,19 and 21-23</u> is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or on Papers	vn from consideration.			
10) 🔲 .	The specification is objected to by the Examiner The drawing(s) filed on is/are: a) acce Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correction The oath or declaration is objected to by the Example 1.	epted or b) objected to by the Edrawing(s) be held in abeyance. See on is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).		
Priority u	nder 35 U.S.C. § 119	•			
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
2) 🔲 Notice 3) 🔯 Inform	e of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) No(s)/Mail Date 10/24 & 9/12/05.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal Pa			

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 8-9 are rejected under 35 U.S.C. 102(e) as being anticipated by Coronel et al (US 5658418).

Coronel et al disclose a plasma etching apparatus capable of determining end point (Abstract) comprising a detector with discrete detection regions (regions Fig 3- 32a and 32b through the optical fiber) for detecting reflected light from an illuminated portion of a substrate (Abstract) illuminated by a light source (29) and selects the best signal/wavelength (*specific optical signal across a frequency band*) out of the two and uses that signal on the basis of previous calculation (Col 14 line 65 to Col 15 line 13) to determine the etch end point and other etch conditions like etch rate.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person

having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

4. Claims 19, 21-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Coronel et al (US 5658418) in view of Liu et al (20030201162).

Coronel et al disclose a plasma etching apparatus capable of determining end point (Abstract) comprising a detector with discrete detection regions (regions Fig 3- 32a and 32b through the optical fiber) for detecting reflected light from an illuminated portion of a substrate (Abstract) illuminated by a light source (29) and selects the best signal/wavelength (*specific optical signal across a frequency band*) out of the two and uses that signal on the basis of previous calculation (Col 14 line 65 to Col 15 line 13) to determine the etch end point and other etch conditions like etch rate.

Coronel discloses spectrometer to detect reflected light from the portion of the substrate illuminated but do not disclose it to be 2D CCD detector.

Liu et al disclose a plasma processing apparatus which could be used for etching (Paragraph 03) or deposition and capable of determining end point (Paragraph 0011) comprising a detector (sensor) for detecting reflected light from plasma emission by optical emission spectroscopy emanating from different discrete regions of the plasma in a direction parallel to the substrate and determining power spectrum (specific optical signal across a frequency band) for each of the different regions (Paragraph 0017) and comparing each of the power spectra to a predetermined value (model optical signal) where end point is determined from one of the detector (sensor) (Paragraph 0077). Further the optical signals are connected to each sensor from discrete region by fiber optics (Paragraph 0020) and received by a CCD array (Paragraph 49).

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Therefore using CCD array as an alternative to photo diode for detection would be obvious to one of ordinary skill in the art at the time of invention.

Response to Arguments

Applicant's arguments filed 1/17/2006 have been fully considered but they are moot in view of new grounds of rejection necessitated by applicant's amendment.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ram N. Kackar whose telephone number is 571 272 1436. The examiner can normally be reached on M-F 8:00 A.M to 5:P.M.

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supervisor, Parviz Hassanzadeh can be reached on 571 272 1435. The fax phone number for the

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Ram Kackar

Primary Examiner AU 1763